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(54) **PHOTOMASK AND METHOD OF FORMING A PARTIAL-DEPTH FEATURE IN A POLYMER FILM**

FOTOMASKE UND VERFAHREN ZUR AUSBILDUNG VON STRUKTURELEMENTEN MIT VERRINGERTER TIEFE IN EINEM POLYMERFILM

EBAUCHE DE MASQUE ET PROCEDE DE FORMATION DE CARACTERISTIQUES DE PROFONDEUR PARTIELLE DANS UN FILM POLYMERIQUE

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EP 1 664 936 B8

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